

## Surface-Site-Selective Study of Si(111)-7×7 Using Auger Photoelectron and Photoelectron Auger-Electron Coincidence Spectroscopy

Takuhiro Kakiuchi<sup>\*1</sup>, Narihiko Fujita<sup>2</sup>, Shogo Hashimoto<sup>2</sup>, Masatoshi Tanaka<sup>2</sup>, and Kazuhiko Mase<sup>3</sup>  
<sup>1</sup>Department of Chemistry, Faculty of Science, Ehime University, 2-5 Bunkyocho, Matsuyama, Ehime 790-8577, Japan

<sup>2</sup>Department of Physics, Faculty of Engineering, Yokohama National University, 79-5 Tokiwadai, Hodogaya-ku, Yokohama 240-8501, Japan

<sup>3</sup>KEK-PF, Tsukuba, Ibaraki 305-0801, Japan

### Introduction

Local valence electronic structures of specific sites of surfaces and interfaces of semiconductor are very important in fundamental surface science and semiconductor industry. Core-Valence-Valence Auger photoelectron coincidence spectroscopy (CVV APECS) provide us with information on the local valence electric structures at specific sites, when the energy resolution of analyzer for photoelectrons is better than the surface core-level shift [1]. On the other hand, photoelectron Auger-electron coincidence spectroscopy (PEACS), where the CVV Auger electrons with a specific kinetic energy are detected by an electron energy analyzer as trigger while photoelectrons in core photoelectron region are measured by another electron energy analyzer, provide us with very surface-sensitive photoelectron spectrum (PES) [2]. The escape depth ( $ED_{PEACS}$ ) of electrons measured in PEACS is shorter than conventional synchrotron radiation photoelectron spectroscopy (SR-PES). The  $ED_{APECS}$  is given by following equation;

$$\frac{1}{ED_{PEACS}} = \frac{1}{\mu_{Pe}} + \frac{1}{\mu_{Ae}}, \quad \mu_{Pe} = \lambda_{Pe} \cos \theta, \quad \mu_{Ae} = \lambda_{Ae} \cos \theta \quad (1),$$

where  $\lambda$  and  $\theta$  denote the inelastic mean free path (IMFP) and the emission angles of the detected electrons, respectively [3]. The  $ED$  in APECS is also estimated by the same equation. In this study we investigated local valence electronic structures of a Si(111)-7×7 surface using APECS and PEACS.

### Results and discussion

Figure 1 (a) shows a Si- $L_{23}VV$ -Si-2p APECS measured in coincidence with Si 2p<sub>3/2</sub> photoelectron of relative binding energy of -0.45 eV, which emitted from the rest-atom sites on Si(111)-7×7 (filled squares with error bars). The width of the APECS in Fig. 1 (a) is much narrower than those of conventional Si- $L_{23}VV$  Auger electron spectrum (open circles, singles AES), indicating the high purity of the Si- $L_{23}VV$  AES component of the rest-atoms. The highest peak of Si- $L_{23}VV$  AES of the rest-atom is shifted by about 1 eV to the higher kinetic energy side relative to that of the singles AES. The results indicate that the binding energy of valence electron band with the highest density of the rest-atoms shifts by a several hundreds meV to lower binding energy side relative to those of the other surface sites.

Figure 1 (b) shows the Si-2p-Si- $L_{23}VV$  PEACS measured in coincidence with Si- $L_{23}VV$  AES of relative

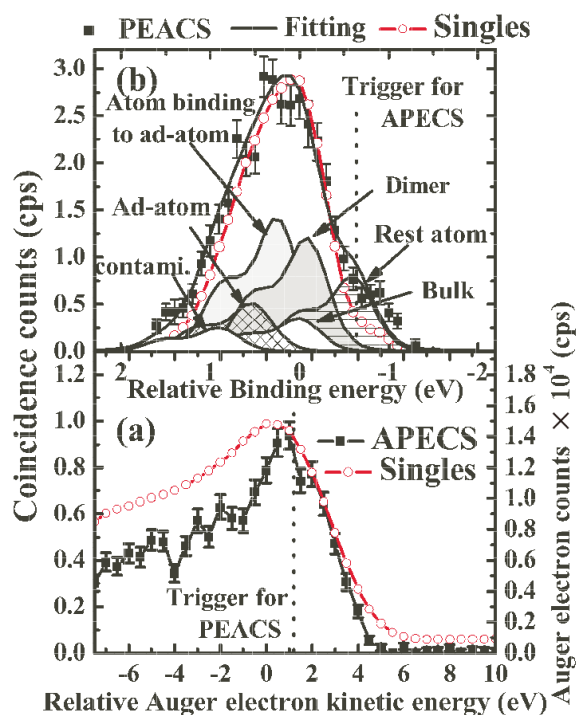


Fig. 1 (a) Si- $L_{23}VV$ -Si-2p APECS and (b) Si-2p-Si- $L_{23}VV$  PEACS.

kinetic energy +1.1 eV (filled squares with error bars). The main peak of the PEACS shifts to higher binding energy side relative to that of conventional Si-2p PES (open circles, singles PES). As the result of a fitting procedure, the total area of surface components constituting Si-2p PES is observed to be increased by about 30%. Si-2p-Si- $L_{23}VV$  PEACS is also used to identify negatively or positively charged components..

### References

- [1] R. A. Bartynski *et al.*, Phys. Rev. Lett. **68**, 2247 (1992).
- [2] G. Stefani *et al.*, J. Electron Spectrosc. Relat. Phenom. **127**, 1 (2002).
- [3] G. A. Sawatzky: in *Auger electron spectroscopy* eds. C. L. Briant and R. P. Messer (Academic Press, San Diego, 1988) Chap. 5, p. 167-243.

\* tkakiuchi@chem.sci.ehime-u.ac.jp